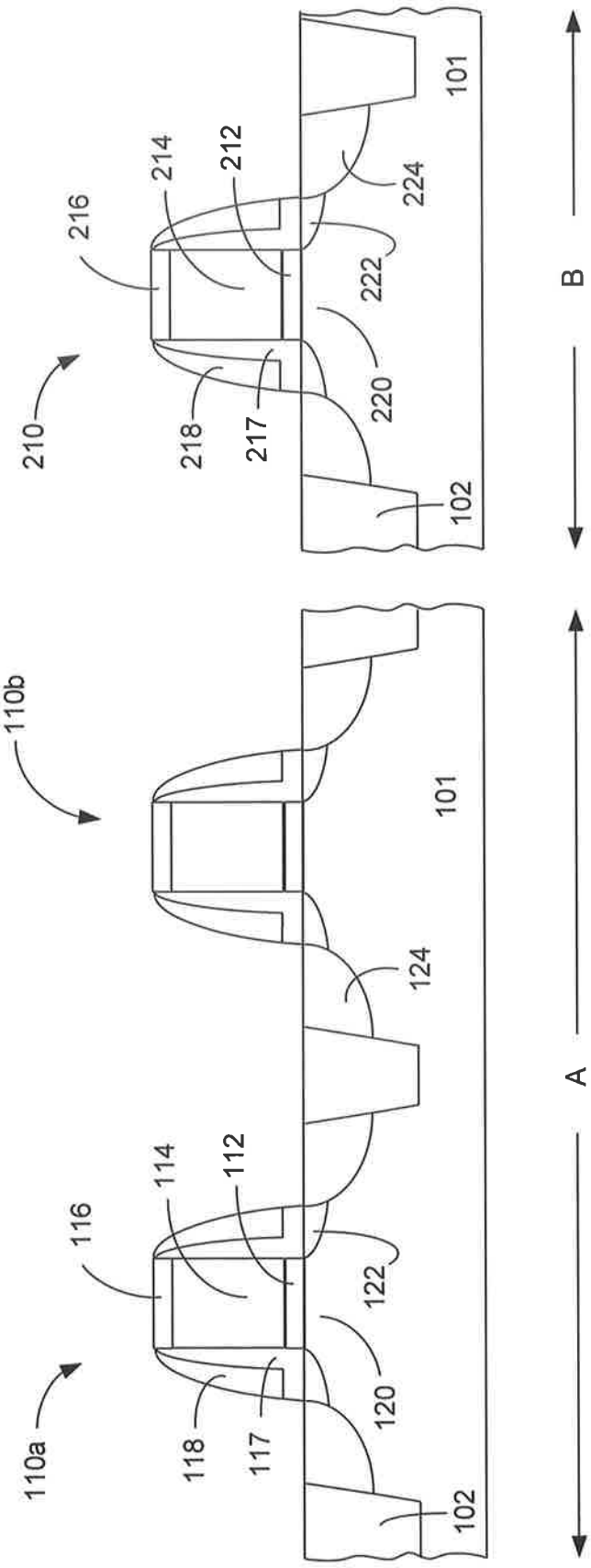

110a
110b
116
114
112
118
117
120
122
124
216
214
212
218
217
220
222
224
101
102
A
B
100

Fig. 1

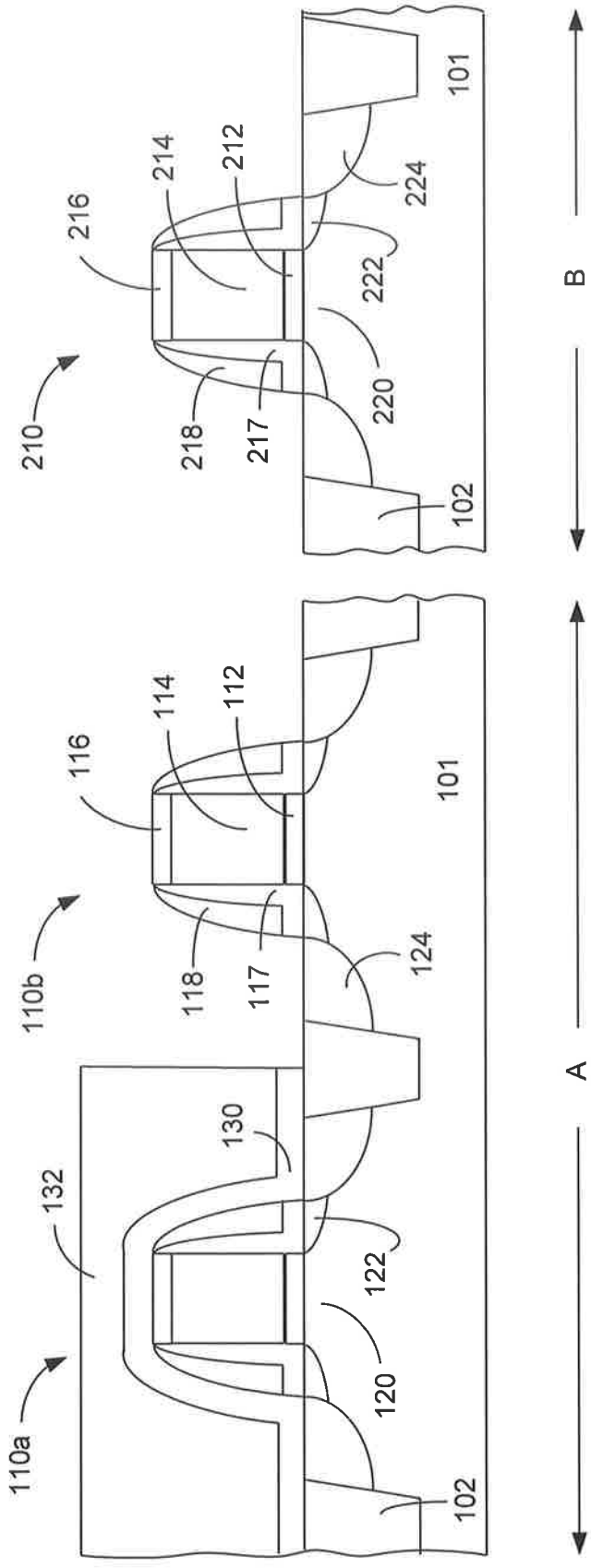

110a
110b
210
132
130
122
120
124
118
117
116
114
112
216
214
212
224
222
220
218
217
102
101
A
B
100

Fig. 2

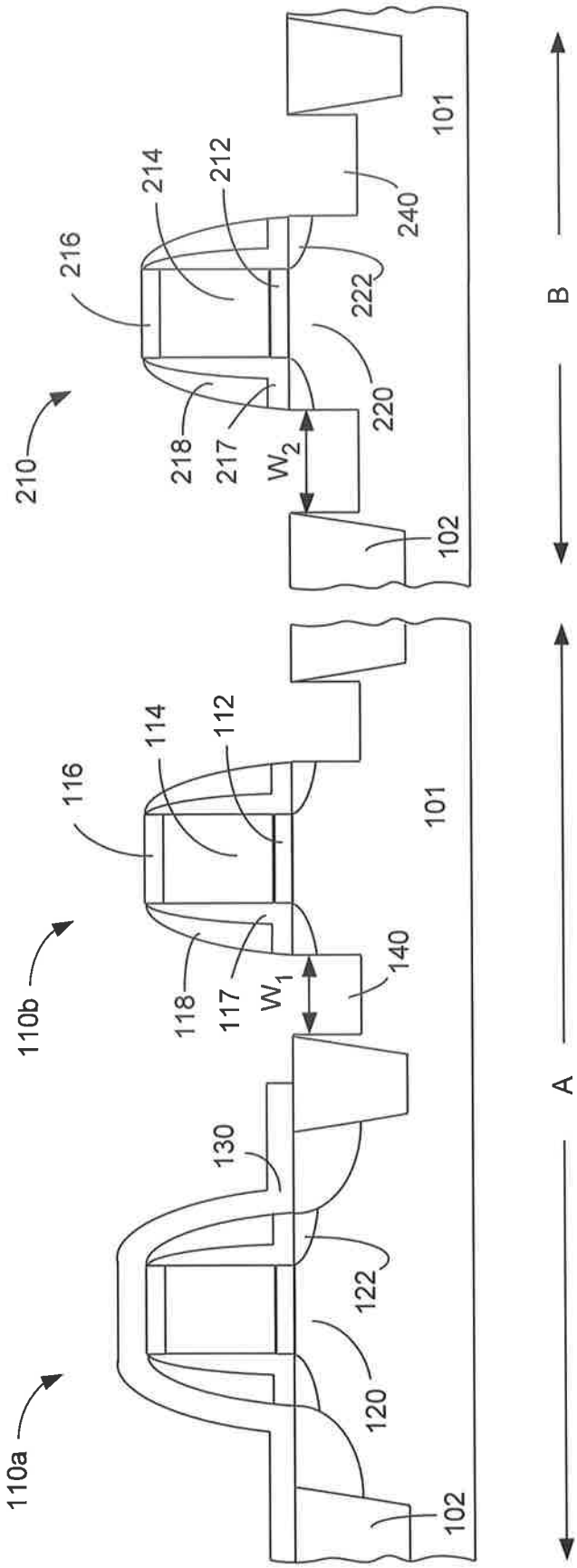

110a
110b
210
116
114
112
216
214
212
118
117
$W_1$
$W_2$
218
217
130
140
240
222
220
122
120
101
102
A
B
100

Fig. 3

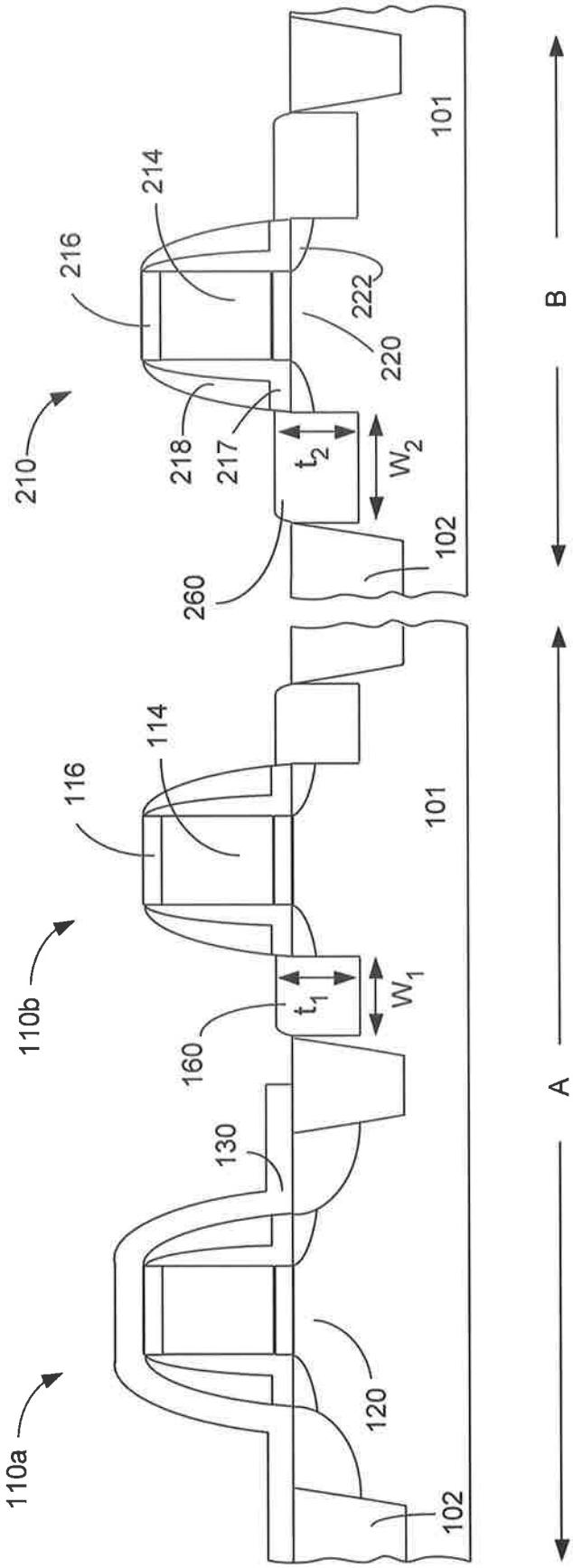

110a
110b
210
100
A
B
101
102
120
130
160
114
116
214
216
218
217
220
222
260
$t_1$
$W_1$
$t_2$
$W_2$

Fig. 4

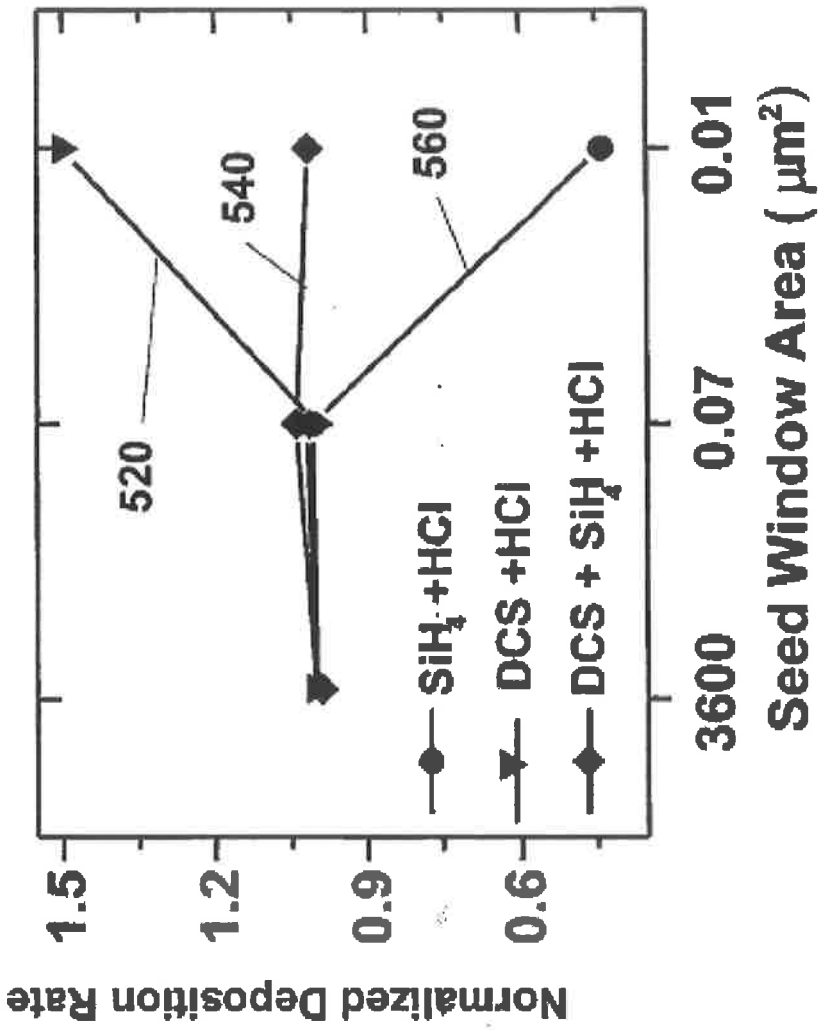

Normalized Deposition Rate
1.5
1.2
0.9
0.6
3600
0.07
0.01
Seed Window Area ( μm²)
520
540
560
SiH₄+HCl
DCS +HCl
DCS + SiH₄ +HCl

Fig. 5